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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/645,773	08/21/2003	Hidehiko Kawaguchi	KAMMON 3.0-069 CONT	8770
530	7590	10/18/2005	EXAMINER	
LERNER, DAVID, LITTENBERG, KRUMHOLZ & MENTLIK 600 SOUTH AVENUE WEST WESTFIELD, NJ 07090			CARRILLO, BIBI SHARIDAN	
			ART UNIT	PAPER NUMBER
			1746	

DATE MAILED: 10/18/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

<b>Office Action Summary</b>	Application No. 10/645,773	Applicant(s) KAWAGUCHI ET AL.	
	Examiner Sharidan Carrillo	Art Unit 1746	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

### Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

### Status

- 1) ☒ Responsive to communication(s) filed on 19 August 2005.
- 2a) ☒ This action is **FINAL**.                      2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

### Disposition of Claims

- 4) ☒ Claim(s) 1,2,5-8 and 12-16 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 1,2,5-8 and 12-16 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

### Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on \_\_\_\_\_ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

### Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All    b) ☐ Some \* c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
  2. ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

### Attachment(s)

- |  |   |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)  | 4) <input type="checkbox"/> Interview Summary (PTO-413)<br>Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)                                   | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152)             |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)<br>Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____  |

**DETAILED ACTION**

***Claim Rejections - 35 USC § 102***

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 1-2, 4, and 8 are rejected under 35 U.S.C. 102(b) as being anticipated by King (4599116).

King teaches a method of employing an aqueous alkaline cleaner for cleaning of aluminum container surfaces. King teaches that it is desirable to subsequently rinse an alkaline cleaned surface with an aqueous based neutral or acidulated rinse solution at a controlled pH to remove residual cleaning solution there from where after it is subjected to further treatments as may be desired or required. In order to avoid any buildup in alkalinity, it is been found necessary to effect an overflow of the rinse and or a neutralization of alkaline buildup such as by the addition of an acid to maintain the pH of the rinse solution at a pH about 7. By maintaining the subsequent water rinse solutions at a neutral or acid pH, the formation of brown stains on the aluminum container bodies is substantially eliminated (col. 7, lines 15-37, col. 12, lines 1-12). Example 4 teaches continuous rinses in a pilot washer. In col. 6, lines 50-51 teach contacting of the substrate by immersion. The limitations of producing of salt would inherently be met by the teachings of King since King teaches performing the same method steps. Additionally, it is notoriously well known in the art that salts are produced by acid-base

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reactions (6759184, 6489353). In reference to claims 2 and 4, refer to col. 7, lines 20-30.

***Claim Rejections - 35 USC § 103***

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

1. Determining the scope and contents of the prior art.
2. Ascertaining the differences between the prior art and the claims at issue.
3. Resolving the level of ordinary skill in the pertinent art.
4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

6. Claims 1-2, 5-8, 12, and 15-16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Olesen et al. (5656097).

Olesen et al. teach a wafer cleaning system. Olesen teach a cleaning tank subjected to sequential flows of one or more diluted cleaning solutions that are injected from the lower end of tank and allowed to overflow to the upper end. Olesen et al. teach cleaning with ammonium hydroxide/hydrogen peroxide/ water, followed by rinsing with cold DI water (col. 4, lines 1-20). Olesen teaches injecting small amount of HF into cold DI water stream (col. 4, lines 45-50) to create the desired concentration of HF for etching (col. 11, lines 45-55). In reference to claims 1, 7-8, and 15, Olesen teaches cleaning with ammonium hydroxide/hydrogen peroxide/ water mixture, followed by rinsing with cold DI water. After a predetermined period of time, acid is added to the rinse bath . Col. 4, lines 17-18 teaches continuing the cold DI water flow. Olesen further teaches overflowing the cleaning solution to the overflow weir 17 and directing it to a drain 23. Olesen fails to teach forming a salt. However, one would reasonably expect a salt to be produced by reaction of the acid with the basic cleaning solution since it is notoriously well known in the art that salts are produced by acid/base reactions (6759184, 6489353). In reference to claim 2, Olesen teaches contacting the wafer with the HF diluted in cold DI water rinse. In reference to claims 5-6, and 12, Olesen teaches that it is conventional in the art to use SC1 and SC2 solutions in the semiconductor manufacturing process. In col. 9, lines 63-65, Olesen teaches Piranha cleaning using sulfuric acid/hydrogen peroxide mixture in combination with the ammonium hydroxide/hydrogen peroxide mixture. In reference to claim 16, it would

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have been obvious to a person of ordinary skill in the art to use the method of Olesen to clean LCD since Olesen teaches using the method to clean wafers and circuit devices.

7. Claims 13-14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Olesen et al. (5656097) as applied to claims 1-2, 5-8, 12, and 15-16 as described in paragraph 6 above, and further in view of Kennison et al. (3898351).

Olesen et al. teach the invention substantially as claimed with the exception of the limitations of claims 13-14. Specifically, Olsen et al. fail to teach measuring the resistivity of the rinse bath to determine the completion of the rinsing. Kennison et al. teach cleaning substrates used in the fabrication of integrated circuits. In col. 3, lines 39-55, Kennison teaches measuring the resistivity in the rinse water in order to determine whether the rinse is adequate. Kennison further teaches setting a resistivity level, such as 12 megaohms, to assure completeness of the rinse. It would have been obvious to a person of ordinary skill in the art to have modified the method of Olesen et al. to include, measuring the resistivity of the rinse bath, as taught by Kennison, for purposes of determining the completeness of the rinsing step.

8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Massicot et al. teach measuring the resistivity of the rinse bath.

### ***Response to Arguments***

9. Applicant argues that King differs from the claimed invention. Applicant argues that the chemicals added in Kings are used to maintain the pH of the rinsing fluid. Applicant further argues that the chemicals of King are not used to convert the chemical

composition of the cleaning chemical. It is unclear what applicant means by this statement. Applicant's arguments are unpersuasive because they are not commensurate in scope with the instantly claimed invention. Applicant further argues that King fails to teach adding the acid to the rinse bath after a predetermined period of time from the start of the rinsing. Applicant's arguments are unpersuasive for the following reasons. King teaches cleaning with an alkaline solution followed by a rinse stage. King further teaches that in subsequent rinse stages, an acid is added to the water to neutralize the alkaline buildup in the rinse solution.

10. The rejections of the claims as being anticipated by Biebl and obvious over Biebl in view of the secondary references are withdrawn in view of arguments and the newly amended claim language. A new grounds of rejection is imposed as discussed above.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire **THREE MONTHS** from the mailing date of this action. In the event a first reply is filed within **TWO MONTHS** of the mailing date of this final action and the advisory action is not mailed until after the end of the **THREE-MONTH** shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

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the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sharidan Carrillo whose telephone number is 571-272-1297. The examiner can normally be reached on Monday-Friday, 6:00a.m-2:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Barr can be reached on 571-272-1414. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

bsc

Sharidan Carrillo  
Primary Examiner  
Art Unit 1746

  
**SHARIDAN CARRILLO**  
**PRIMARY EXAMINER**